Application

a step (b-5) of forming insulation layers between the first signal electrodes after the step (b-1),

wherein upper surfaces of the insulation layers are on the same level as upper surfaces of the first signal electrodes.

49. (Amended) An embedded device comprising:

the ferroelectric memory device as defined in claim 1; and
at least one component selected from a group including a flash memory, a
processor, an analog circuit, and an SRAM.

REMARKS

Claims 1-49 are pending. By this Preliminary Amendment, the specification and claims 35-37, 47 and 49 are amended. No new matter is added.

The attached Appendix includes marked-up copies of each rewritten paragraph (37 C.F.R. §1.121(b)(1)(iii)) and claim (37 C.F.R. §1.121(c)(1)(ii)).

Prompt and favorable examination on the merits is respectfully requested.

Respectfully submitted,

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